

Search Notes



Application/Control No.	Applicant(s)/Patent under Reexamination
10/621,520	LIU ET AL.
Examiner	Art Unit
Anthony J. Paviglianiti	1626

SEARCHED

INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner

SEARCH NOTES (INCLUDING SEARCH STRATEGY)

	DATE	EXMR
Restriction requirement	11/24/2004	AJP
CAPLUS structure search	11/18/2004	AJP
EAST JP 04122754, JP 54004997, JP 04057812, US Patent 6232430 and WO 9817644	11/18/2004	AJP
EAST - search resins, epoxy & maleimido	11/8/2004	AJP
CAPLUS - structure search $\text{Y}=\text{N}(\text{CH}_2\text{-epoxy})_2$	11/19/2004	AJP
CAPLUS - structure search broadened aryl or cyclo or alkyl between maleimido and epoxy substituents	11/19/2004	AJP
CAPLUS CAOLD term searches- oxirane & pyrrole and dione and epoxy	11/19/2004	AJP